

Supporting Information

Steering the Methane Dry Reforming Reactivity of Ni/La₂O₃ Catalysts by Controlled *In Situ* Decomposition of doped La₂NiO₄ Precursor Structures

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Section A: BET analysis

Table S1: BET surface area (m^2g^{-1}) of the four catalysts before and after catalytic DRM at 800 °C for 90 min, obtained from 5 point measurements recorded at 77 K after degassing the samples under vacuum for 10 h at 200 °C.

Sample	Before DRM	After DRM
$\text{La}_2\text{Ni}_{0.9}\text{Cu}_{0.1}\text{O}_4$	3.252	4.241
$\text{La}_2\text{Ni}_{0.8}\text{Cu}_{0.2}\text{O}_4$	2.218	3.896
$\text{La}_{1.8}\text{Ba}_{0.2}\text{Ni}_{0.9}\text{Cu}_{0.1}\text{O}_4$	3.695	4.748
$\text{La}_{1.8}\text{Ba}_{0.2}\text{NiO}_4$	4.549	3.021

Section B: Electron microscopy analysis of $\text{La}_{1.8}\text{Ba}_{0.2}\text{NiO}_4$ and $\text{La}_{1.8}\text{Ba}_{0.2}\text{Ni}_{0.9}\text{Cu}_{0.1}\text{O}_4$ in the states before and after DRM at 800 °C.

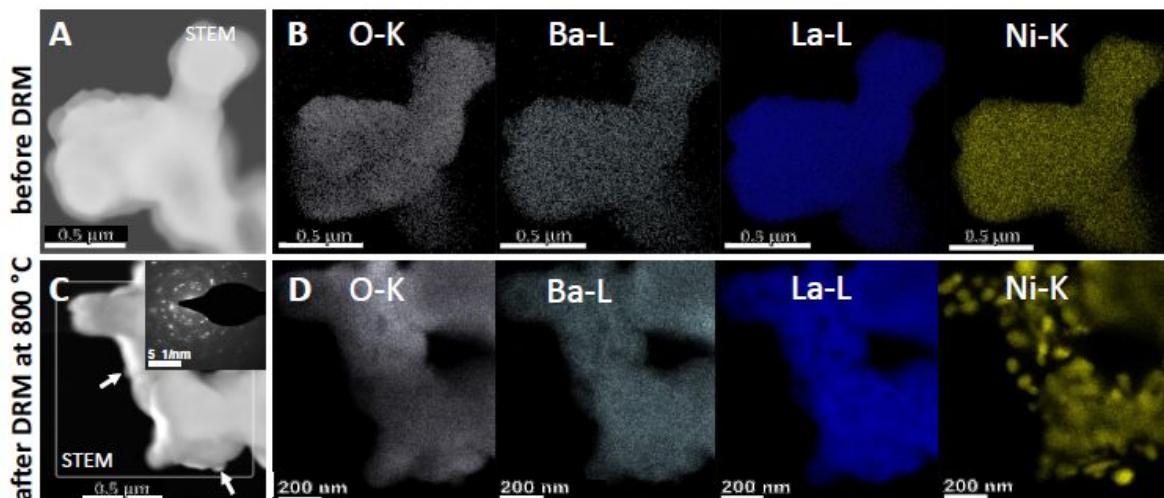


Figure S1: Electron microscopy analysis of $\text{La}_{1.8}\text{Ba}_{0.2}\text{NiO}_4$ in the initial and DRM-spent state at 800 °C. Panels A and C: HAADF images, Panels B and D: EDX analysis of the O-K, Ba-L, La-L and Ni-K.

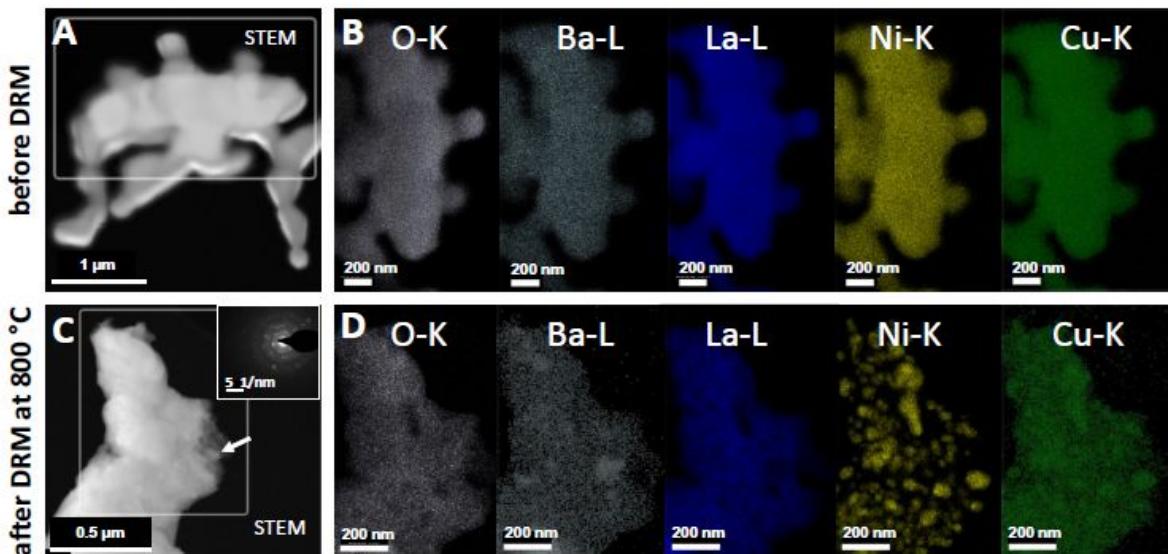


Figure S2: Electron microscopy analysis of $\text{La}_{1.8}\text{Ba}_{0.2}\text{Ni}_{0.9}\text{Cu}_{0.1}\text{O}_4$ in the initial and DRM-spent state at 800 °C. Panels A and C: HAADF images, Panels B and D: EDX analysis of the O-K, Ba-L, La-L, Cu-K and Ni-K.

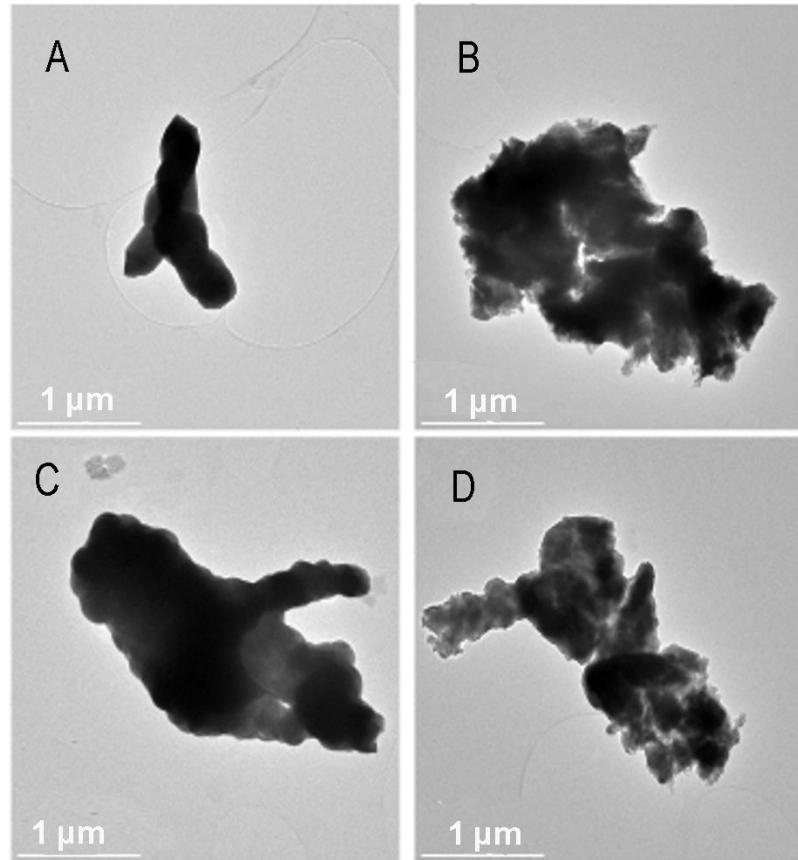


Figure S3: Transmission electron microscopy overview images of $\text{La}_{1.8}\text{Ba}_{0.2}\text{NiO}_4$ and $\text{La}_{1.8}\text{Ba}_{0.2}\text{Ni}_{0.9}\text{Cu}_{0.1}\text{O}_4$ in the initial (Panels A and C, respectively) and the DRM-spent state (Panels B and D, respectively).

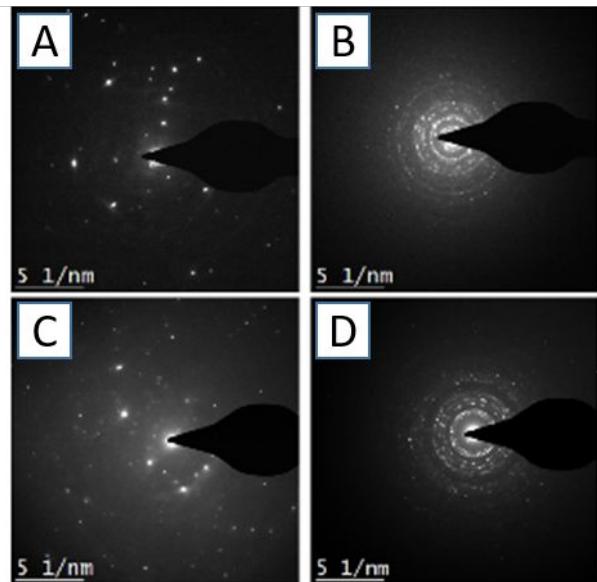


Figure S4: Selected area electron diffraction patterns of $\text{La}_{1.8}\text{Ba}_{0.2}\text{NiO}_4$ and $\text{La}_{1.8}\text{Ba}_{0.2}\text{Ni}_{0.9}\text{Cu}_{0.1}\text{O}_4$ in the initial (Panels A and C, respectively) and the DRM-spent state (Panels B and D, respectively).

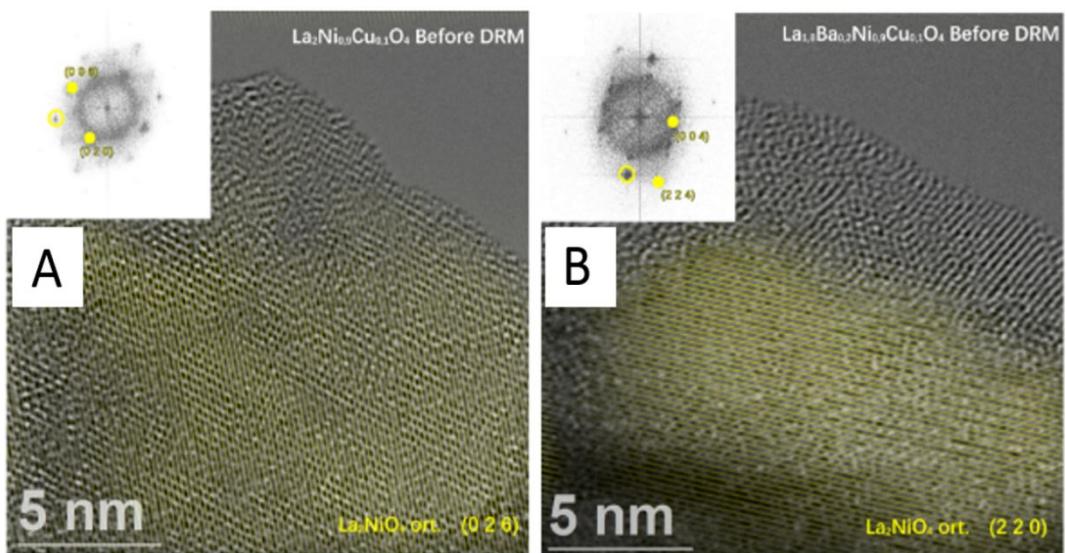


Figure S5: Aberration-corrected high-resolution electron microscopy images of $\text{La}_2\text{Ni}_{0.9}\text{Cu}_{0.1}\text{O}_4$ (Panel A) and $\text{La}_{1.8}\text{Ba}_{0.2}\text{Ni}_{0.9}\text{Cu}_{0.1}\text{O}_4$ (Panel B) in the initial state.

Representative lattice fringes of the orthorhombic La_2NiO_4 structure have been Fourier-filtered and accordingly color-coded to highlight the presence of individual grains.

Section C: Additional XRD analysis

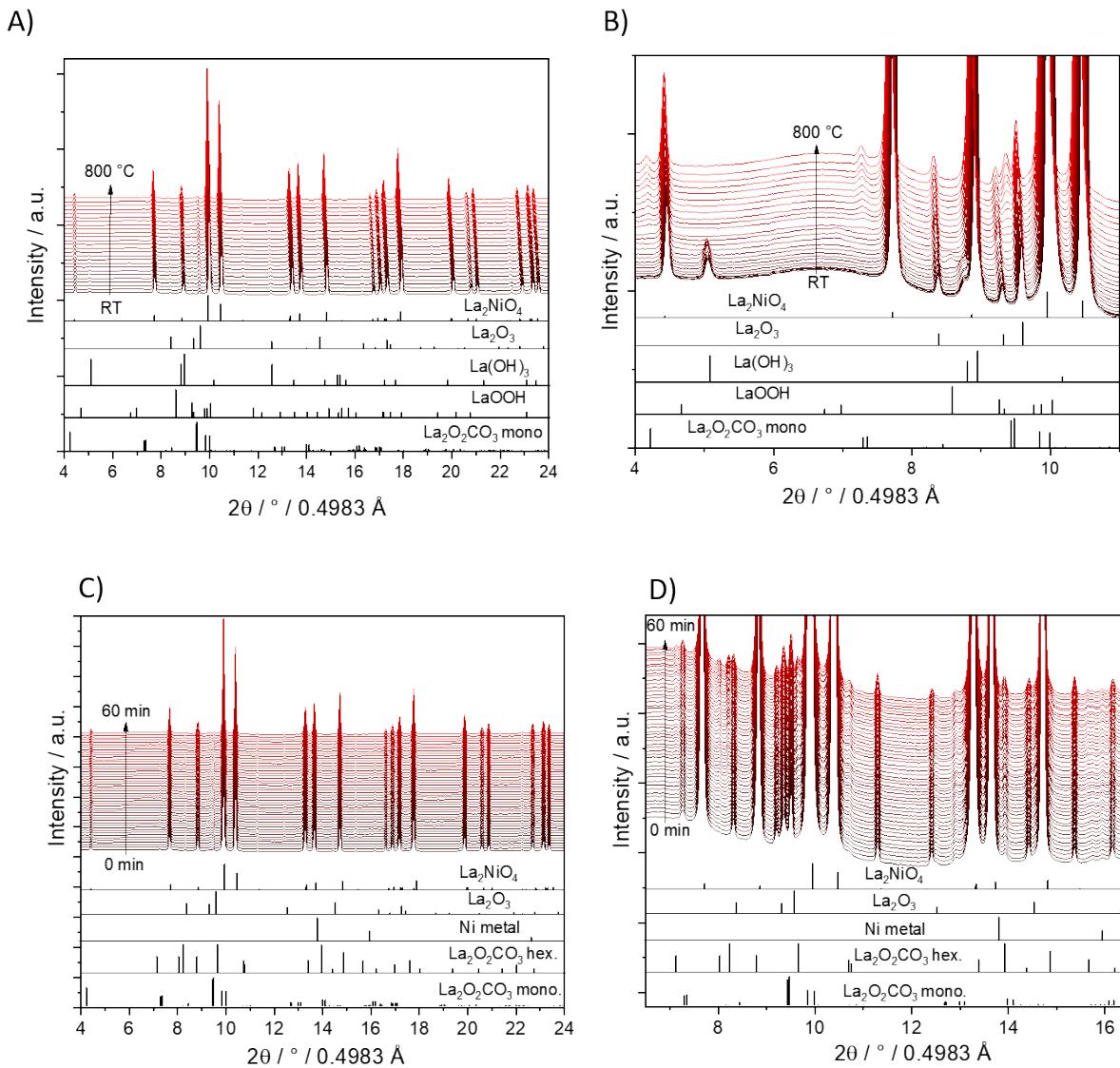


Figure S6: Panel A: *In situ* collected XRD patterns of $\text{La}_{1.8}\text{Ba}_{0.2}\text{NiO}_4$ during heating up to 800 °C under DRM conditions. Panels B focus on a narrower 2θ window for closer analysis. The lower panel indicates the phase assignment to the respective reference structures. Panel C: *In situ* collected XRD patterns of $\text{La}_{1.8}\text{Ba}_{0.2}\text{NiO}_4$ during holding at 800 °C for 60 min under DRM

conditions. Panels D focus on a narrower 2θ window for closer analysis. The lower panel indicates the phase assignment to the respective reference structures.

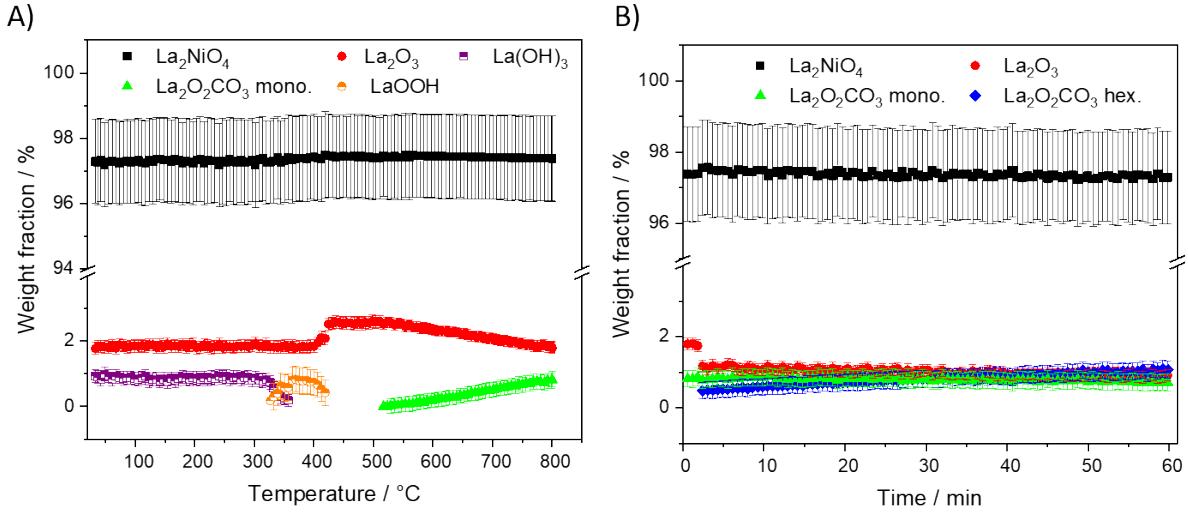


Figure S7: Weight fractions of different crystalline phases formed during DRM as a function of temperature (A) and time at 800 °C (B) obtained by Rietveld refinement of the *in situ* collected XRD patterns of La_{1.8}Ba_{0.2}NiO₄.

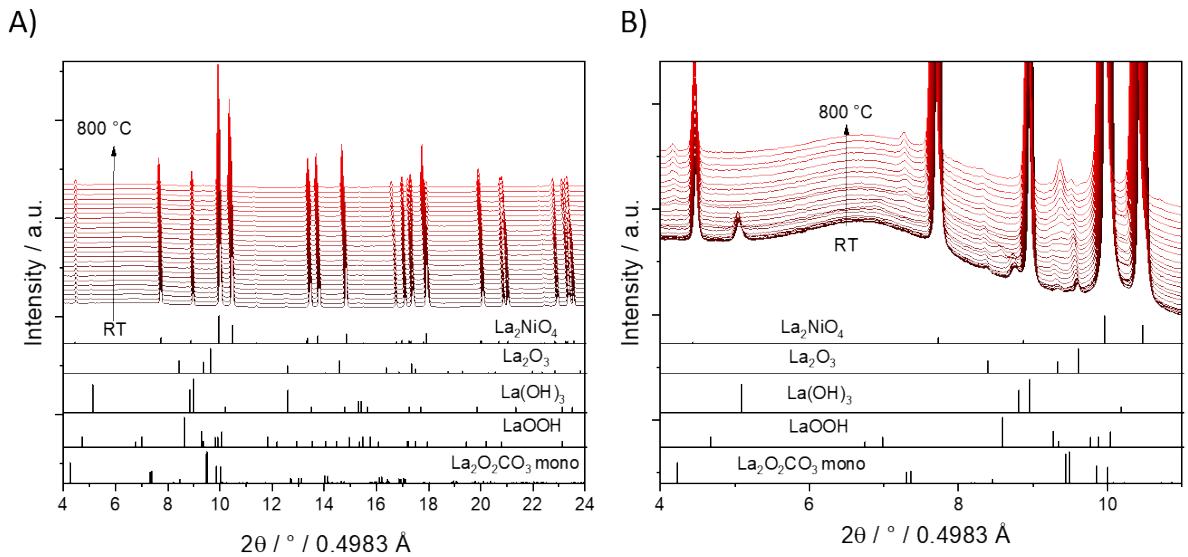


Figure S8: *In situ* collected XRD patterns of La₂Ni_{0.9}Cu_{0.1}O₄ during heating up to 800 °C under DRM conditions. Panels B focus on a narrower 2θ window for closer analysis. The lower panel indicates the phase assignment to the respective reference structures.

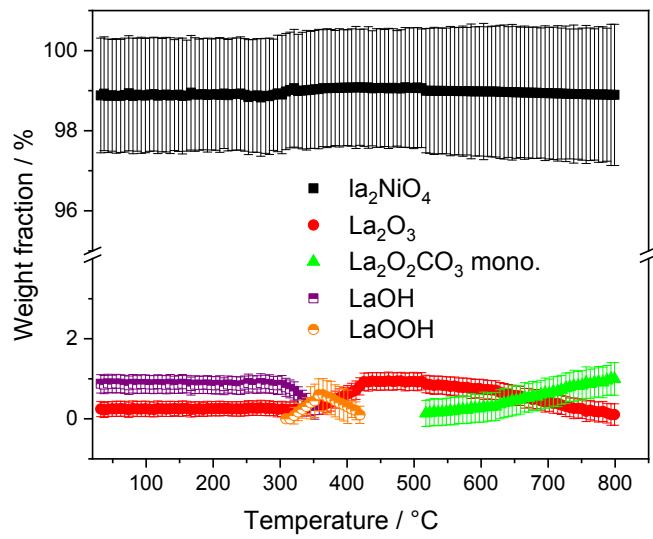


Figure S9: Weight fractions of different crystalline phases formed during DRM as a function of temperature obtained by Rietveld refinement of the in situ collected XRD patterns of $\text{La}_2\text{Ni}_{0.9}\text{Cu}_{0.1}\text{O}_4$.

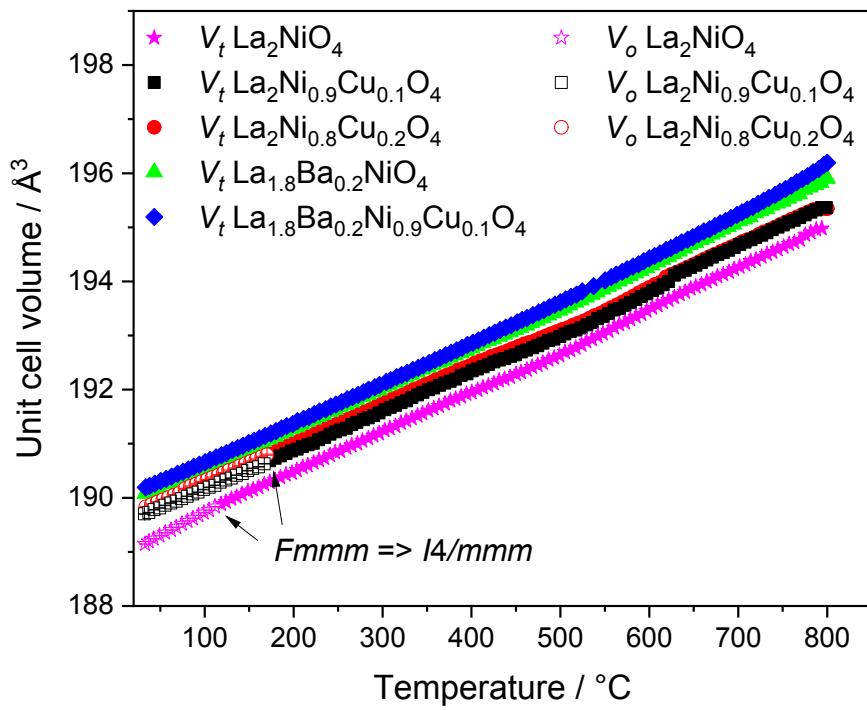


Figure S10: Evolution of the unit cell volume of pure and doped La_2NiO_4 samples as a function of temperature in the DRM mixture.

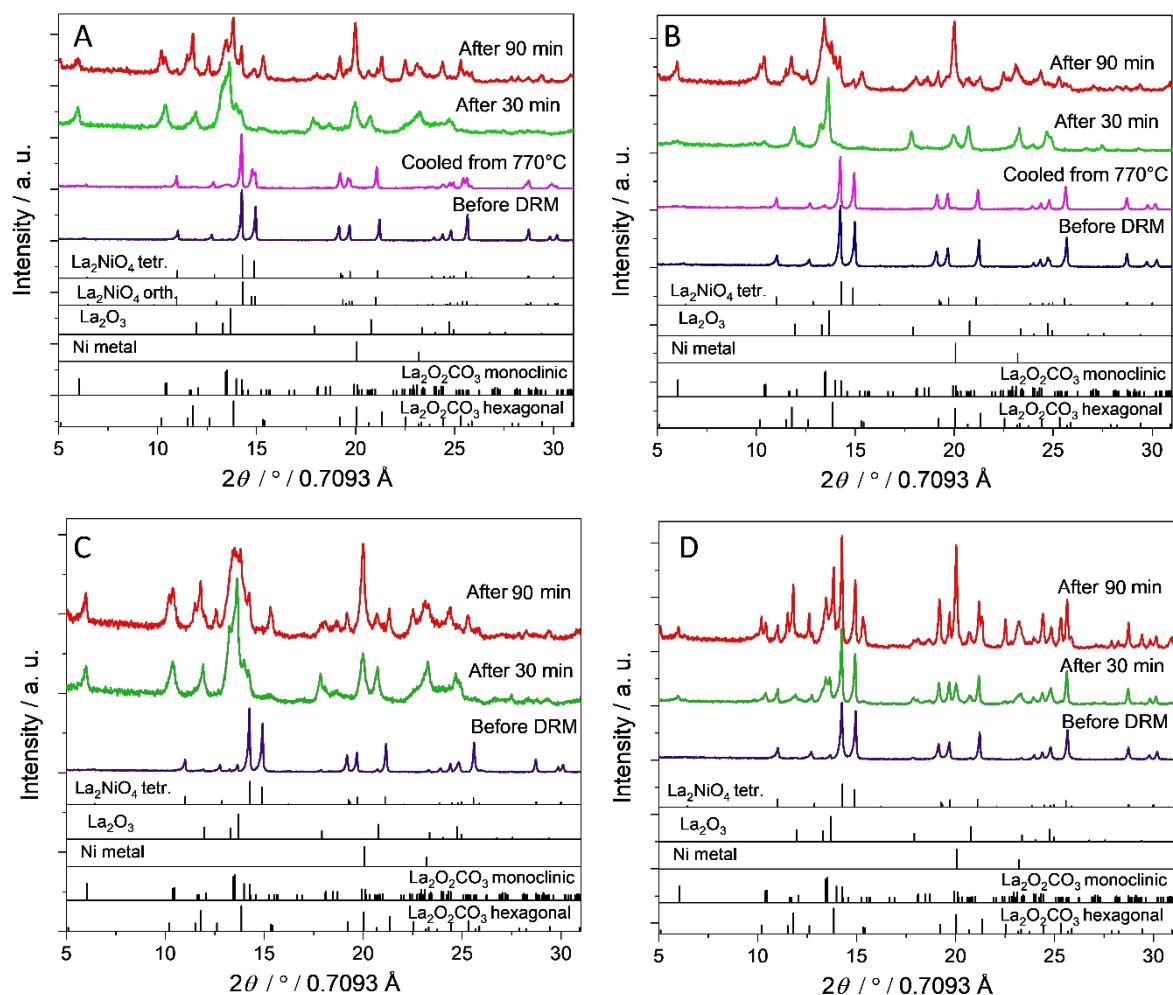


Figure S11: *Ex situ* collected PXRD patterns of $\text{La}_2\text{Ni}_{0.8}\text{Cu}_{0.2}\text{O}_4$ (A), $\text{La}_{1.8}\text{Ba}_{0.2}\text{Ni}_{0.9}\text{Cu}_{0.1}\text{O}_4$ (B), $\text{La}_2\text{Ni}_{0.9}\text{Cu}_{0.1}\text{O}_4$ (C), and $\text{La}_{1.8}\text{Ba}_{0.2}\text{NiO}_4$ (D) Ruddlesden-Popper materials before and after a catalytic DRM ($\text{CO}_2:\text{CH}_4:\text{He} = 1:1:3$) runs in a total gas flow of 100 mL min^{-1} at different conditions.

Section D: Additional XANES analysis

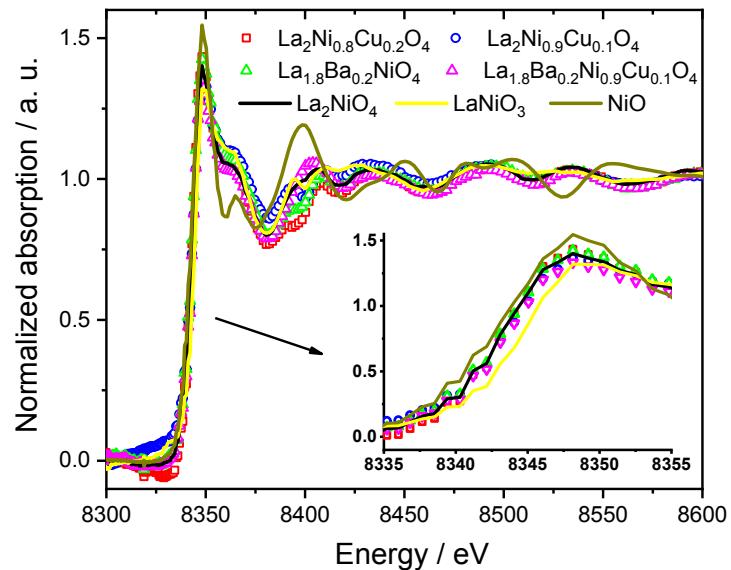


Figure S12: Normalized Ni K -edge X-ray absorption fine structure (XANES) of pure and doped La_2NiO_4 Ruddlesden-Popper materials as well of reference materials (NiO and LaNiO_3).

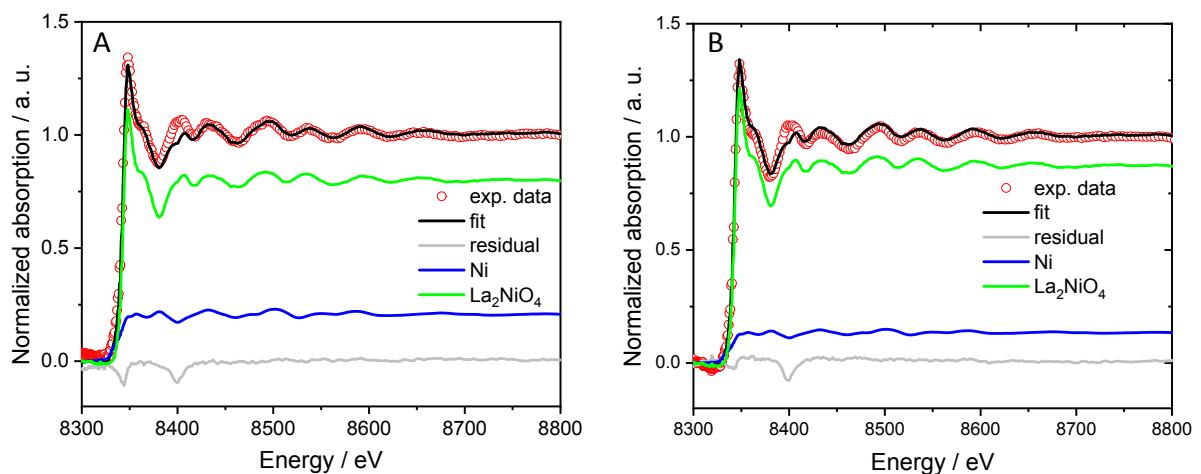


Figure S13: Linear combination fitting (LCF) of normalized Ni K -edge XANES spectra of $\text{La}_2\text{Ni}_{0.8}\text{Cu}_{0.2}\text{O}_4$ and $\text{La}_{1.8}\text{Ba}_{0.2}\text{Ni}_{0.9}\text{Cu}_{0.1}\text{O}_4$ with those of reference materials (NiO and La_2NiO_4).

Section E: XPS analysis

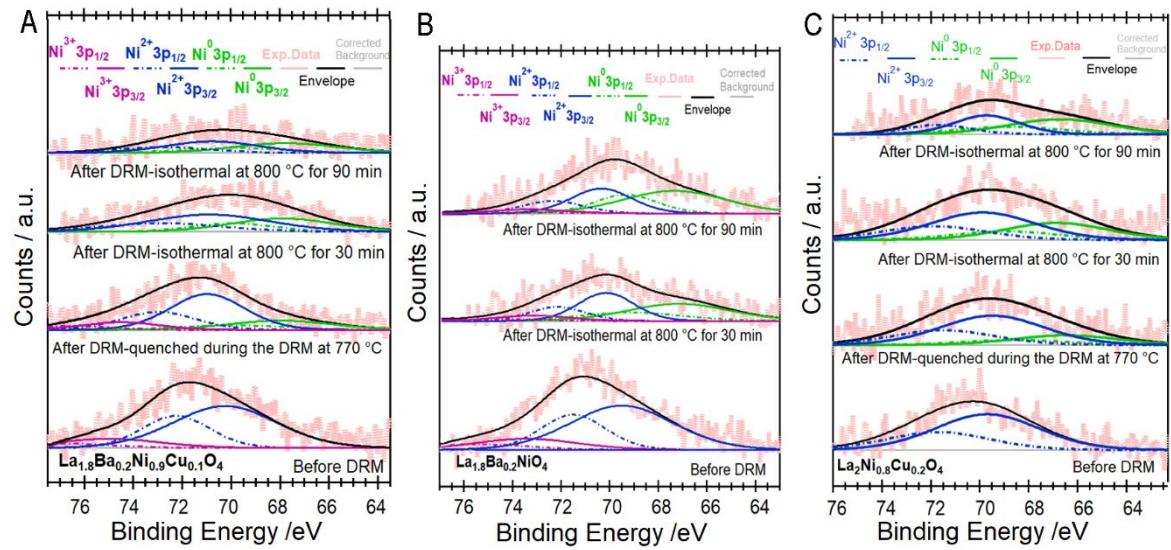


Figure S14: Full set of Ni 3p species of $\text{La}_{1.8}\text{Ba}_{0.2}\text{Ni}_{0.9}\text{Cu}_{0.1}\text{O}_4$ (Panel A), $\text{La}_{1.8}\text{Ba}_{0.2}\text{NiO}_4$ (Panel B) and $\text{La}_2\text{Ni}_{0.8}\text{Cu}_{0.2}\text{O}_4$ (Panel C) after selected DRM treatments.